

	Hit s	Search Text	DBs
18	1	((photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) same ((multi\$4 or four or plural\$4 or three) near12 beam near22 interfer\$4)) and (expos\$4 or irradiat\$4 or illuminat\$4) and interference and cur\$4 and (inorganic or fluorescein or siloxane or silane) and rhodamine and pyrolysis	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
19	1	((photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) same ((multi\$4 or four or plural\$4 or three) near12 beam near22 interfer\$4)) and (expos\$4 or irradiat\$4 or illuminat\$4) and interference and cur\$4 and (inorganic or fluorescein or siloxane or silane or oligomer\$4 or sol\$4gel) and rhodamine and pyrolysis	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
20	7	((photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) same ((multi\$4 or four or plural\$4 or three) near12 beam near22 interfer\$4)) and (expos\$4 or irradiat\$4 or illuminat\$4) and interference and cur\$4 and (inorganic or fluorescein or siloxane or silane or oligomer\$4 or sol\$4gel) and rhodamine	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
21	7	((photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) same ((multi\$4 or four or plural\$4 or three) near12 beam near22 interfer\$4)) and (expos\$4 or irradiat\$4 or illuminat\$4) and interference and cur\$4 and (inorganic or fluorescein or siloxane or silane or oligomer\$4 or sol\$4gel) and rhodamine and (sinter\$4 or pyrolysis or anneal\$4 or heat\$4)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
24	1	((photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) same ((multi\$4 or four or plural\$4 or three) near12 beam near22 interfer\$4)) and ((photoreactive or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4) same (pattern or void or interstitial or (line near9 space)) same (deposit\$4 or coat\$4 or form\$4 or film\$4) same (zirconia or alumina or silica or (metal near9 oxide) or semiconductor) same treat\$4) and interference and cur\$4 and (inorganic or fluorescein or siloxane or silane)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
25	63	(photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) and ((photoreactive or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4) same (pattern or void or intersitial or (line near9 space) or grat\$4)) and ((grat\$4 or waveguide) same (deposit\$4 or coat\$4 or form\$4 or film\$4) same (zirconia or alumina or silica or (metal near9 oxide) or semiconductor or silicon or Si) same treat\$4)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
26	27	(photoreact\$4 or photocur\$5 or photosensitive or photoactiv\$5 or (light near6 sensit\$6)) and ((photoreactive or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4) same (pattern or void or intersitial or (line near9 space) or grat\$4) same (deposit\$4 or coat\$4 or form\$4 or film\$4) same (zirconia or alumina or silica or (metal near9 oxide) or semiconductor) same treat\$4) and interference	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB